

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|------|---|---|------------------|---------|------------------|
| L1 | 3120 | (438/613,614).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | OFF | 2005/08/18 16:14 |
| L2 | 2960 | (257/737,738).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | OFF | 2005/08/18 16:27 |
| L3 | 0 | (self adj1 etch adj1 stop) and annealing and metallic and (altered adj1 electrical adj1 resistivity) and ((one or 1) adj1 micron) | US-PGPUB | OR | OFF | 2005/08/18 16:30 |
| L4 | 0 | (etch adj1 stop) and annealing and metallic and (altered adj1 electrical adj1 resistivity) and ((one or 1) adj1 micron) | US-PGPUB | OR | OFF | 2005/08/18 16:30 |